## AMENDMENTS IN THE CLAIMS

- (currently amended) A method of etching a specimen, comprising the steps of:
- (a) providing an ion beam gun with a grid having a surface with a plurality of holes extending therethrough for filtering a ion beam emitted by the gun;
- supporting the specimen adjacent to the gun and rotating one of the specimen and (b) the gun relative to the other;
  - emitting an ion beam from the gun through the grid and toward the specimen; and (c)
- blocking at least some of the holes in the grid by covering a radial swath of the (d) grid from a center of the grid to a perimeter of the grid such that the ion beam emitted by the gun is prevented from passing therethrough for improving an etch depth uniformity of the specimen.
- The method of claim 1 wherein step (d) comprises mounting a plate to the 2. (original) surface of the grid to block said at least some of the holes.
- The method of claim 1 wherein step (d) comprises blocking approximately 3. (original) 1 to 5% of the holes in the grid.
- (canceled) 4.
- The method of claim 1 wherein step (b) comprises rotating the specimen 5. (original) relative to the gun.

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